AMENDMENTS TO THE SPECIFICATION:

Please replace the paragraph beginning on page 2, line18, and ending on page 2,

line 23, with the following amended paragraph:

In the field emission display taught by U.S. Patent No. 5,710,483, a second gate

electrode is formed by deposition of a metal material. In a field emission display disclosed in

Korean Patent No. 2000-7115 Laid Open No. 2001-0081496, a metal mesh, manufactured

separately from a cathode plate and an anode plate, is bridged to the cathode plate and the

anode plate via spacers provided between the anode plate and the cathode plate

Please replace the paragraph beginning on page 3, line 1, and ending on page 3, line

6, with the following amended paragraph:

On the other hand, in the case of the field emission display taught by Korean Patent

No. 2000-7115 Laid Open No. 2001-0081496, a second gate electrode, i.e., a mesh grid,

electrode is formed of a metal plate. Accordingly, unlike in U.S. Patent No. 5,710,483, there

is no limit in the size of the second gate electrode. Rather, the thickness of the second gate

electrode can be freely selected, and thus it is possible to effectively control electron beams.

Please insert the following new paragraph at page 6, line 5, after the heading BRIEF

DESCRIPTION OF THE DRAWINGS:

The patent or application file contains at least one drawing executed in color. Copies

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